Roll No. Total No. of Pages : 02

Total No. of Questions: 09

B.Tech. (CSE/EE/IT/ME) (Sem-7) ELECTRONIC DEVICES

Subject Code: BTEC-301-18

M.Code: 90606

Date of Examination: 10-06-2023

Time: 3 Hrs. Max. Marks: 60

#### INSTRUCTIONS TO CANDIDATES:

- 1. SECTION-A is COMPULSORY consisting of TEN questions carrying TWO marks each.
- 2. SECTION-B contains FIVE questions carrying FIVE marks each and students have to attempt any FOUR questions.
- 3. SECTION-C contains THREE questions carrying TEN marks each and students have to attempt any TWO questions.

#### SECTION-A

# 1. Write briefly:

- a) Describe the behaviour of p-n junction diode under forward and reverse biased conditions.
- b) Give the Energy band diagrams of Intrinsic and Extrinsic Semiconductors
- c) Differentiate between Drift current and Diffusion current in a semiconductor.
- d) What do you understand by: i) Knee voltage and ii) Breakdown voltage?
- e) What is Ebers Moll model in Transistors?
- f) Mention any two advantages of MOSFET over JFET.
- g) What is the purpose of Sputtering in Fabrication process of ICs or devices?
- h) Give the circuit symbols for Zener diode, Tunnel diode, Varactor diode and a Transistor.
- i) Derive the relation between  $\alpha$  and  $\beta$  with respect to BJT.
- j) What is the significance of etching?

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#### SECTION-B

- 2. Draw Ebers-Moll model and hence explain Transistor action.
- 3. Explain the construction and working of a MOSFET. Give its V I characteristics.
- 4. What are the three important configurations in which the transistor can be connected? Discuss any one of them.

## 5. **Define:**

Diffusion and Ion-Implantation. What are the various types of Ion-implantation techniques that are commonly used in fab line?

6. What do you mean by oxidation process? Explain in detail. Also give characteristics of different oxide films.

### SECTION-C

- 7. Draw and explain Half-wave and full wave (centre tapped & bridge) rectifiers 10 with suitable circuit diagrams. Which one is preferable and why?
- 8. In a CE configuration, the collector supply voltage is 10V. When a resistor RC=1K $\Omega$  is connected in the collector circuit, the voltage drop across it is 0.5 V. For  $\alpha$ =0.98, determine the collector-emitter voltage and the base current.
- 9. How doping done using ion implantation? Draw and explain the working of ion implanter.

NOTE: Disclosure of Identity by writing Mobile No. or Making of passing request on any page of Answer Sheet will lead to UMC against the Student.

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